Application No. Applicant(s)	
Notice of Allowability Examiner Art Unit	
Notice of Allowability Examiner Art Unit	
David User and the 1763	
Parviz Hassanzaden 1765	
The MAILING DATE of this communication appears on the cover sheet with the correspondence address	
All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.	
1. X This communication is responsive to <u>10/14/03</u> .	
2. 🔀 The allowed claim(s) is/are <u>36,39,40 and 43-53</u> .	
3. A The drawings filed on 10/14/03 are accepted by the Examiner.	
4. ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) ☐ All b) ☐ Some* c) ☐ None of the:	
 Certified copies of the priority documents have been received. 	
2. ☐ Certified copies of the priority documents have been received in Application No	
3. Copies of the certified copies of the priority documents have been received in this national stage application from	the
International Bureau (PCT Rule 17.2(a)).	
* Certified copies not received:	
5. Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application) since a speci reference was included in the first sentence of the specification or in an Application Data Sheet. 37 CFR 1.78.	ic
(a) The translation of the foreign language provisional application has been received.	
6. Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121 since a specific reference was in the first sentence of the specification or in an Application Data Sheet. 37 CFR 1.78.	cluded
Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements below. Failure to timely comply will result in ABANDONMENT of this application. THIS THREE-MONTH PERIOD IS NOT EXTENS	noted ABLE.
7. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE (INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.	F
8. ☐ CORRECTED DRAWINGS (as "replacement sheets") must be submitted. (a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached	
1) hereto or 2) to Paper No	
(b) including changes required by the proposed drawing correction filed, which has been approved by the Examiner	
(c) Including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No.	
(e) Initiating oranges required by the analysis and analysis analysis and analysis analysis and analysis analysis analysis and analysis analysis analysis analysi	_
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the margin according to 37 CFR 1.121(d).	
9. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.	
Attachment(s)	
1☐ Notice of References Cited (PTO-892) 5☐ Notice of Informal Patent Application (PTO-152)	
2☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 6☐ Interview Summary (PTO-413), Paper No	
3 Information Disclosure Statements (PTO-1449 or PTO/SB/08), 7 Examiner's Amendment/Comment	
Haper No	
Parviz Hassanzadeh Primary Examiner Art Unit: 1763	

Application/Control Number: 09/855,972

Art Unit: 1763

DETAILED ACTION

Allowable Subject Matter

Claims 36, 39, 40, 43-53 are allowed.

The following is an examiner's statement of reasons for allowance: a plasma processing apparatus including a *bias power source* coupled to a substrate support and configured to apply a potential to the substrate so that *electrons from plasma are attracted to the substrate*.

Neither of the prior art of the record teaches or suggests a plasma etching apparatus wherein a bias power source coupled to a substrate support being adapted to apply a potential on the substrate so that electrons from plasma are attracted toward the substrate.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Parviz Hassanzadeh whose telephone number is (703)308-2050. The examiner can normally be reached on Tuesday-Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Gregory Mills can be reached on (703)308-1633. The fax phone number for the organization where this application or proceeding is assigned is (703)872-9306.

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Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703)308-0661.

Parviz Hassanzadeh

Parviz Hassanzadeh Primary Examiner Art Unit 1763

November 20, 2003